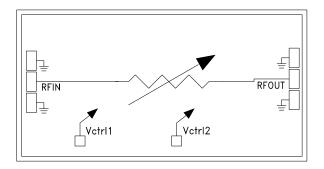


Typical Applications

The HMC985A is ideal for:

- · Point-to-Point Radio
- VSAT Radio
- Test Instrumentation
- · Microwave Sensors
- · Military, ECM & Radar

Functional Diagram



Features

Wide Bandwidth: 20 - 50 GHz

Excellent Linearity: +30 dB Input IP3

Wide Attenuation Range: 35 dB

Die Size: 2.78 x 1.37 x 0.1 mm

General Description

The HMC985A is an absorptive Voltage Variable Attenuator (VVA) which operates from 20 - 50 GHz and is ideal in designs where an analog DC control signal must be used to control RF signal levels over a 35 dB dynamic range. It features two shunt-type attenuators which are controlled by two analog voltages, Vctrl1 and Vctrl2. Optimum linearity performance of the attenuator is achieved by first varying Vctrl1 of the first attenuation stage from -5V to 0V with Vctrl2 fixed at -5V. The control voltage of the second attenuation stage, Vctrl2, should then be varied from -5V to 0V with Vctrl1 fixed at 0V.

Furthermore, if the Vctrl1 and Vctrl2 pins are connected together it is possible to achieve the full analog attenuation range with only a small degradation in input IP3 performance. Applications include AGC circuits and temperature compensation of multiple gain stages in microwave point to point and VSAT radios.

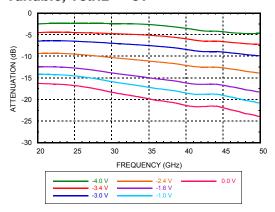
Electrical Specifications, $T_{\Delta} = +25$ °C, See Test Conditions

Parameter	Frequency	Min.	Тур.	Max.	Units
	20 - 27		2.4	3.1	dB
nsertion Loss	27 - 35		2.3	3.4	dB
	35 - 50		3.2	4.0	dB
	20 - 27	34	40		dB
Attenuation Range	27 - 35	38	41		dB
	35 - 50	40	45		dB
Input Return Loss			13		dB
Output Return Loss			13		dB
Input Third Order Intercept (two-tone input Power = 10 dBm Each Tone) [1]			30		dBm

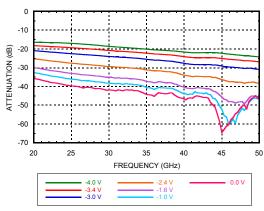
[1] Vctrl2 = -5, Vctrl1 = -3.2 worst case



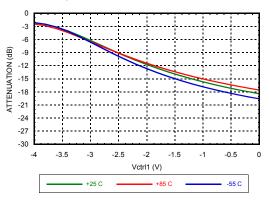
Attenuation vs. Frequency over Vctrl = Variable, Vctrl2 = -5V



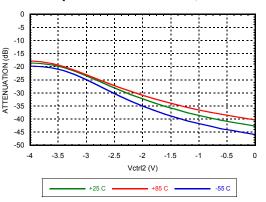
Attenuation vs. Frequency over Vctrl1 = 0V, Vctrl2 = Variable



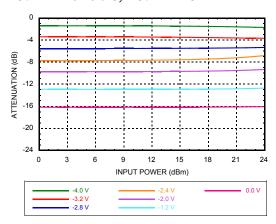
Attenuation vs. Vctrl1 Over Temperature @ 30 GHz, Vctrl2 = -5V



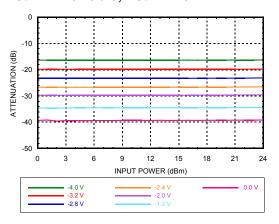
Attenuation vs. Vctrl2
Over Temperature @ 30 GHz, Vctrl1 = 0V



Attenuation vs. Pin @ 24 GHz Vctrl1 = Variable, Vctrl2 = -5V



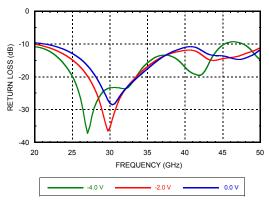
Attenuation vs. Pin @ 24 GHz Vctrl2 = Variable, Vctrl1 = 0V



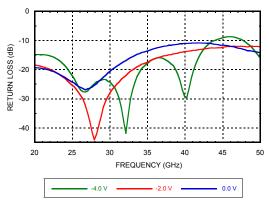


out Return Loss Input

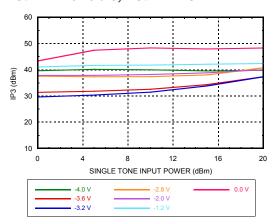
Input Return Loss Vctrl1 = Variable, Vctrl2 = -5V



Output Return Loss Vctrl1 = Variable, Vctrl2 = -5V

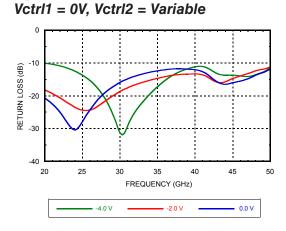


Input IP3 vs. Input Power @ 24 GHz Vctrl1 = Variable, Vctrl2 = -5V



[1] Worst Case IP3

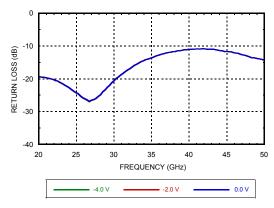
Input Return Loss



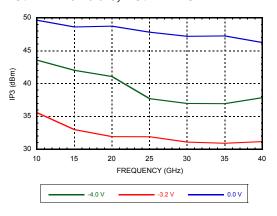
GaAs MMIC VOLTAGE - VARIABLE

ATTENUATOR, 20 - 50 GHz

Output Return Loss Vctrl1 = 0V, Vctrl2 = Variable



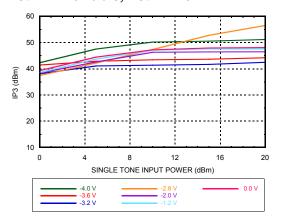
Input IP3 vs. Frequency @ 10dBm Vctrl1 = Variable, Vctrl2 = -5V



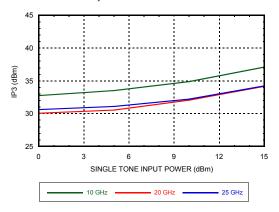


Input IP3 vs. Input Power @ 24 GHz Vctrl2 = Variable, Vctrl1 = 0V

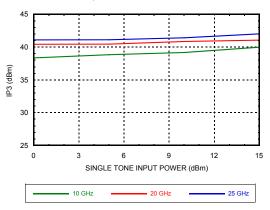
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Input IP3 vs Input Power over Frequency Vctrl1 = -3.2V, Vctrl2 = -5V^[1]

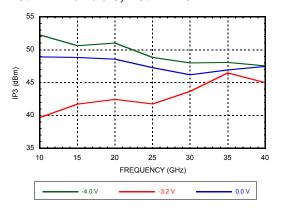


Input IP3 vs Input Power over Frequency Vctrl2 = -3.2V, $Vctrl1 = 0V^{[1]}$

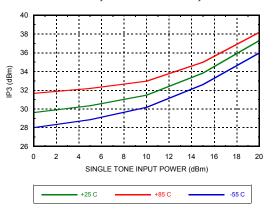


[1] Worst Case IP3

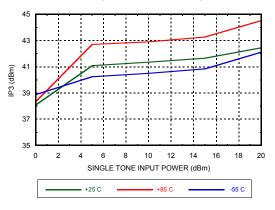
Input IP3 vs. Frequency @ 10dBm Vctrl2 = Variable, Vctrl1 = 0V



Input IP3 vs. Input Power Over Temperature @ 24 GHz, Vctrl1 = -3.2V, Vctrl2 = -5V^[1]

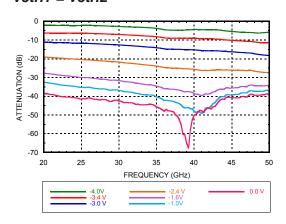


Input IP3 vs Input Power over Temperature @ 24 GHz, Vctrl2 = -3.2V, Vctrl1 = 0V^[1]

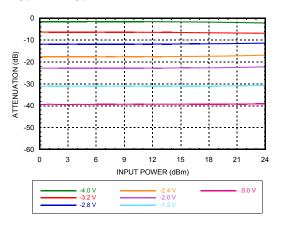




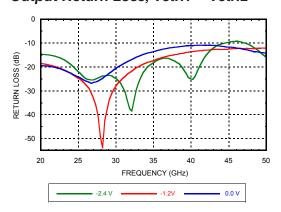
Attenuation vs Frequency Over Vctrl Vctrl1 = Vctrl2



Attenuation vs. Pin @ 24 GHz Over Vctrl Vctrl1 = Vctrl2

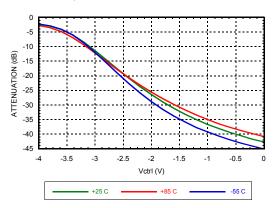


Output Return Loss, Vctrl1 = Vctrl2

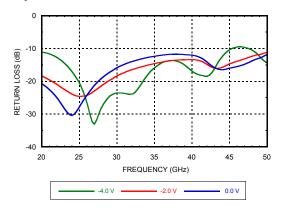


GaAs MMIC VOLTAGE - VARIABLE ATTENUATOR, 20 - 50 GHz

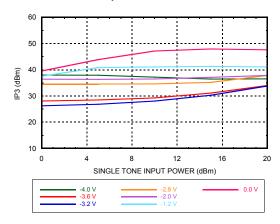
Attenuation vs. Vctrl Over Temperature @ 35 GHz, Vctrl1 = Vctrl2



Input Return Loss, Vctrl1 = Vctrl2



Input IP3 vs. Input Power Over Vctrl @ 24 GHz, Vctrl1 = Vctrl2

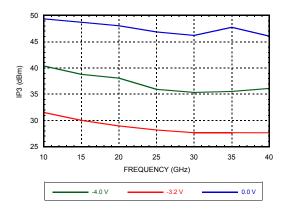




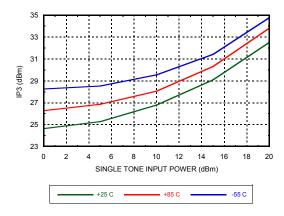
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GaAs MMIC VOLTAGE - VARIABLE ATTENUATOR, 20 - 50 GHz

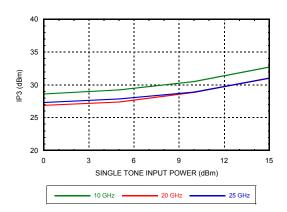
Input IP3 vs. Frequency Vctrl1 = Vctrl2



Input IP3 vs. Input Power Over Temperature @ 24 GHz Vctrl1 = Vctrl2



Input IP3 vs. Input Power Over Frequency Vctrl1 = Vctrl2



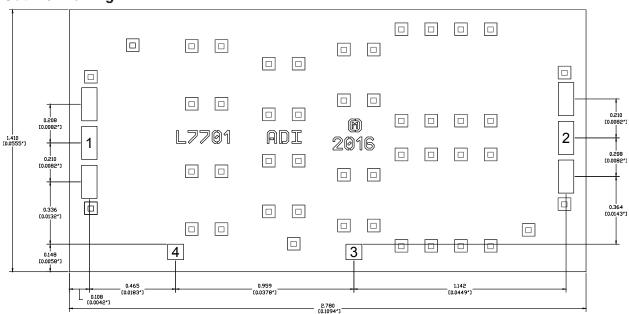


Absolute Maximum Ratings

	J -	
Control Voltage	+0.3 to -6.0V	
Input RF Power	30 dBm	
Maximum Junction Temperature	175 °C	
Thermal Resistance (R _{TH}) (junction to ground paddle)	65 °C/W	
Operating Temperature	-40°C to +85°C	
Storage Temperature	-65°C to 150°C	
ESD Sensitivity (HBM)	Class 1B	



Outline Drawing



Die Packaging Information [1]

Standard		Alternate	
	GP-2 (Gel Pack)	[2]	

- [1] Refer to the "Packaging Information" section for die packaging dimensions.
- [2] For alternate packaging information contact Hittite Microwave Corporation.

NOTES:

- 1. ALL DIMENSIONS ARE IN INCHES [MM]
- 2. DIE THICKNESS IS .004"
- 3. TYPICAL BOND PAD IS 0.0026" [0.066] SQUARE
- 4. BACKSIDE METALLIZATION: GOLD
- 5. BOND PAD METALLIZATION: GOLD
- 6. BACKSIDE METAL IS GROUND.
- 7. CONNECTION NOT REQUIRED FOR UNLABELED BOND PADS.
- 8. OVERALL DIE SIZE ± .002



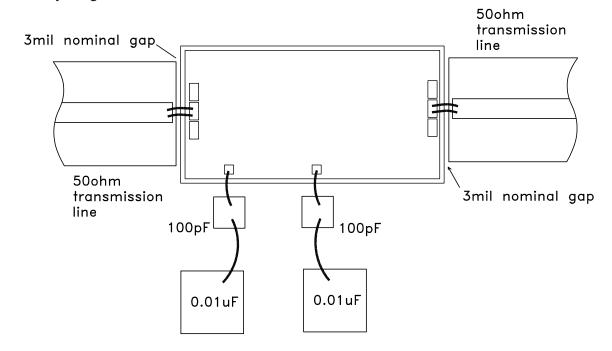
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GaAs MMIC VOLTAGE - VARIABLE ATTENUATOR, 20 - 50 GHz

Pad Descriptions

Pad Number	Function	Description	Pin Schematic	
1	RFIN	This pad is DC coupled and matched to 50 Ohms	RFINO	
2	RFOUT	This pad is DC coupled and matched to 50 Ohms	ORFOUT	
3	Vetrl1	Control Voltage 1	Vctrl10+	
4	Vctrl2	Control Voltage 2	Vctrl20+	
Die Bottom	GND	Die bottom must be connected to RF/DC ground	GND =	

Assembly Diagram



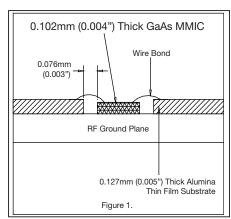


Mounting & Bonding Techniques for Millimeterwave GaAs MMICs

The die should be attached directly to the ground plane eutectically or with conductive epoxy (see HMC general Handling, Mounting, Bonding Note).

50 Ohm Microstrip transmission lines on 0.127 mm (5 mil) thick alumina thin film substrates are recommended for bringing RF to and from the chip (Figure 1). If 0.254 mm (10 mil) thick alumina thin film substrates must be used, the die should be raised 0.150 mm (6 mils) so that the surface of the die is coplanar with the surface of the substrate. One way to accomplish this is to attach the 0.102 mm (4 mil) thick die to a 0.150 mm (6 mil) thick molybdenum heat spreader (moly-tab) which is then attached to the ground plane (Figure 2).

Microstrip substrates should be located as close to the die as possible in order to minimize bond wire length. Typical die-to-substrate spacing is 0.076 mm to 0.152 mm (3 to 6 mils).



Handling Precautions

Follow these precautions to avoid permanent damage.

Storage: All bare die are placed in either Waffle or Gel based ESD protective containers, and then sealed in an ESD protective bag for shipment. Once the sealed ESD protective bag has been opened, all die should be stored in a dry nitrogen environment.

Cleanliness: Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

Static Sensitivity: Follow ESD precautions to protect against $> \pm 250$ V ESD strikes.

Transients: Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pickup.

0.102mm (0.004") Thick GaAs MMIC

Wire Bond

0.076mm
(0.003")

RF Ground Plane

0.150mm (0.006") Thick
Moly Tab

0.254mm (0.010") Thick Alumina
Thin Film Substrate
Figure 2.

General Handling: Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers. The surface of the chip may have fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

Mounting

The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy. The mounting surface should be clean and flat.

Eutectic Die Attach: A 80/20 gold tin preform is recommended with a work surface temperature of 255 °C and a tool temperature of 265 °C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290 °C. DO NOT expose the chip to a temperature greater than 320 °C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

Epoxy Die Attach: Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position. Cure epoxy per the manufacturer's schedule.

Wire Bonding

Ball or wedge bond with 0.025 mm (1 mil) diameter pure gold wire. Thermosonic wirebonding with a nominal stage temperature of 150 °C and a ball bonding force of 40 to 50 grams or wedge bonding force of 18 to 22 grams is recommended. Use the minimum level of ultrasonic energy to achieve reliable wirebonds. Wirebonds should be started on the chip and terminated on the package or substrate. All bonds should be as short as possible <0.31 mm (12 mils).



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GaAs MMIC VOLTAGE - VARIABLE ATTENUATOR, 20 - 50 GHz

Notes:

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